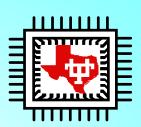
# Optical Backplane and Clock Signal Distribution Systems

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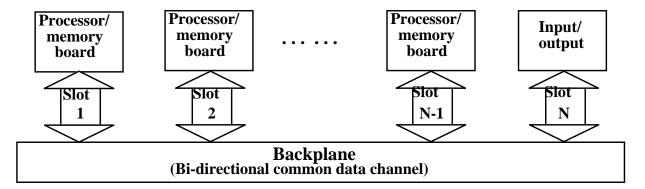


### **Outline**

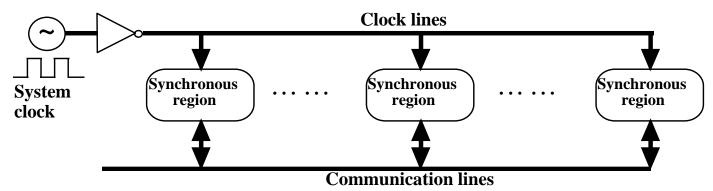
- (1) Introduction to backplane and clock signal distribution systems
- (2) Limitations of electrical interconnection
- (3) Optical realization of backplane and clock signal distribution systems
- (4) System characterization
- (5) Proposed future works

# Definitions of backplane and clock distribution systems

#### **Bi-directional backplane system:**



#### **Clock signal distribution system:**



### What's wrong with electrical interconnection?

### **Increase in computing power**

<=> shrink in clock cycle time and pulse widths => increase in bandwidth to keep signal integrity

#### **Limitations of electrical interconnection:**

capacitive loading crosstalk reflection switching noise skew power dissipation

=> Bandwidth of electrical backplane is limited

## Limitations of electrical interconnection Examples

Processor speed as high as 500 MHz

But board-to-board data rate ~ 100 Mb/s

VMEbus and Futurebus data rate < 100 Mb/s

PCI bus: maximum clock rate 66 MHz

=> Optical interconnection necessary

in high speed (> 200 MHz), long distance (> 1 cm) communications

### Advantages of optical interconnection

Transmission media (waveguide or free-space)

more bandwidth without

transmission line effects capacitive loading complicated termination

### **High speed optoelectronic devices**

transmitter: fast modulation with small current

receiver: high sensitivity with large dynamic range

### Optical interconnection in VLSI systems Various schemes

### **Fiber optics:**

flexibility in geometry of detector positions suitable for long distance communication (e.g., machine-to-machine)

bulky; point-to-point connection

### **Waveguide optics:**

suitable for chip-to-chip interconnection

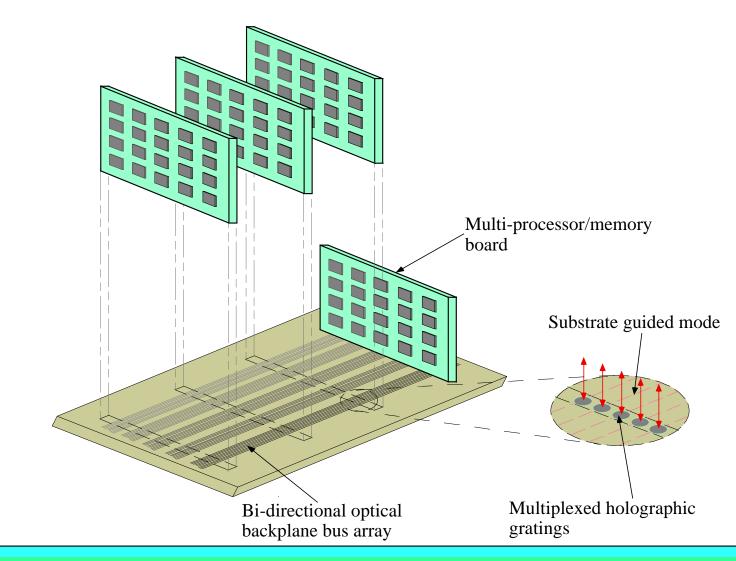
45 °waveguide mirror not compatible with VLSI technology

### **Free-space optics:**

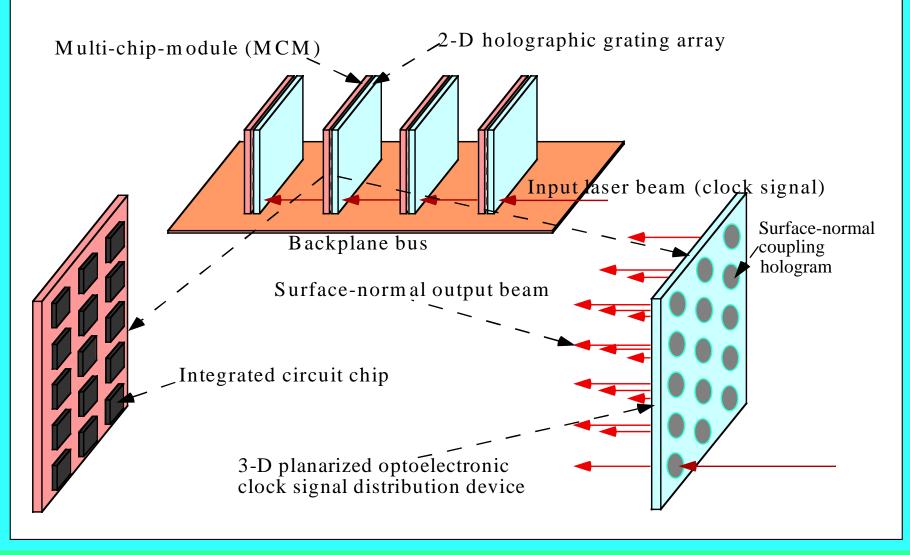
massive fan-out; large degree of freedom; lower propagation delay

control of beam steering

# Optical realization of bi-directional backplane system

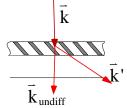


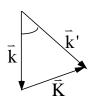
# Optical realization of clock signal distribution system

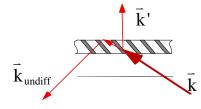


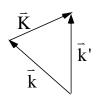
## Design of holographic grating elements

**Single holographic gratings:** 



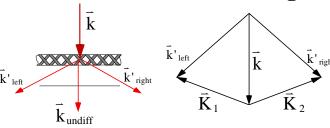


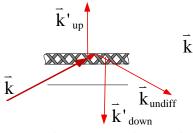


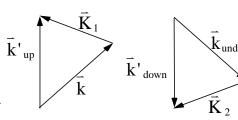


### Multiplexed holographic gratings:

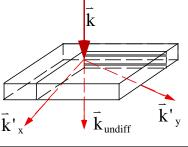
diffract light into opposite directions

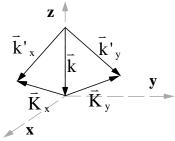


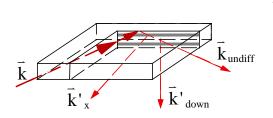


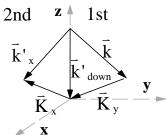


diffract light into perpendicular directions

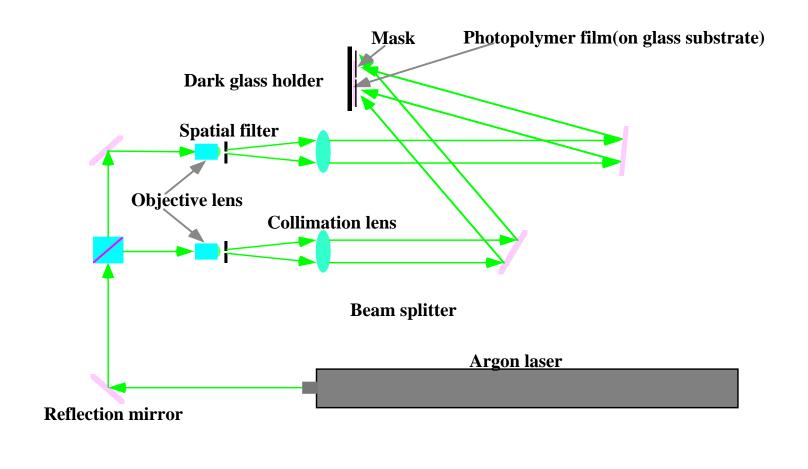






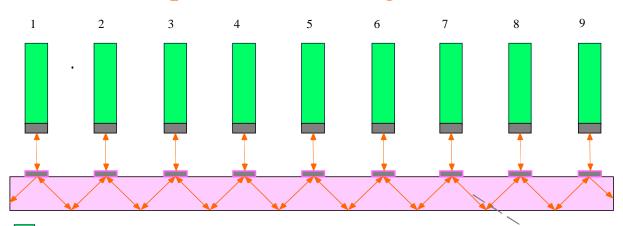


## Fabrication of holographic grating elements



## Bi-directional optical backplane bus with single bus line

Backplane configuration



Processor/memory module

Waveguiding plate

- High-speed transceiver
- Waveguide hologram for bi-directional coupling

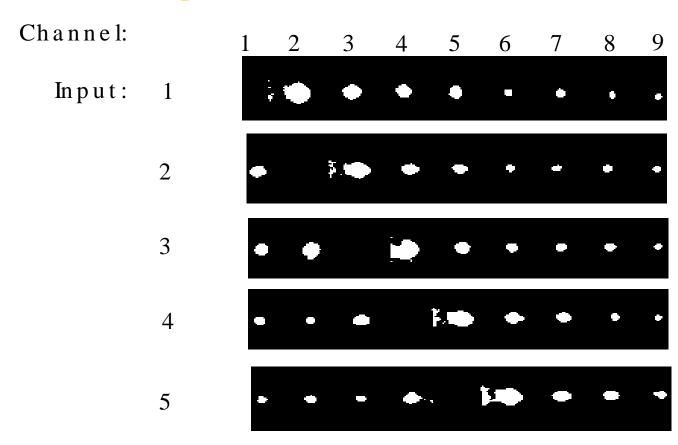
# Bi-directional optical backplane with a single bus line

#### Channel communication

Input:	1	2	3	4	5	6	7	8	9
Channel:	<b>(X)</b>		•	•		•	•	•	
2	•	$\otimes$	•		•	•	•	•	•
3	•	•	<b>©</b>		•	•	•	•	•
4	•	•	•	<b>®</b>	•	•	•	•	•
5	•	•	•	•	(X)	•	•	•	•
6	•	•	•	•	•	X	•	•	•
7	•	•	•	•	•	•	$\bigcirc$	•	•
8	•	•	•	•	•	•	•		•
9	•	•		•	•	•	•	•	

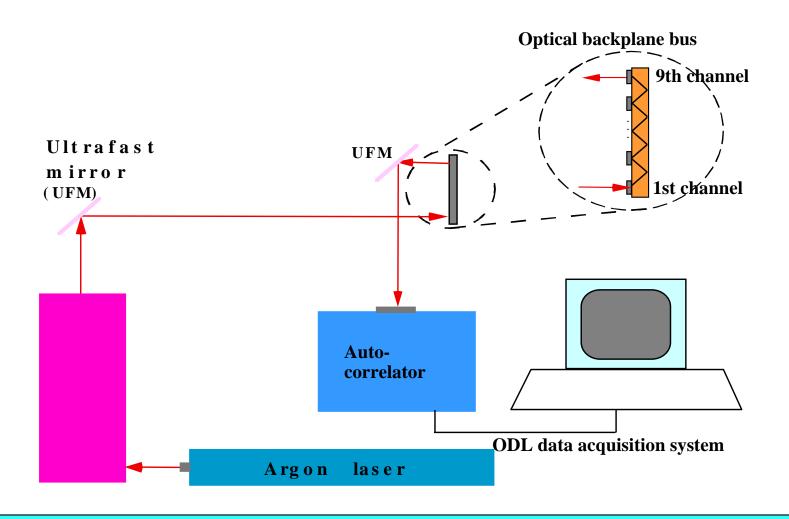
# Bi-directional optical backplane bus with single bus line

Experiment demonstration

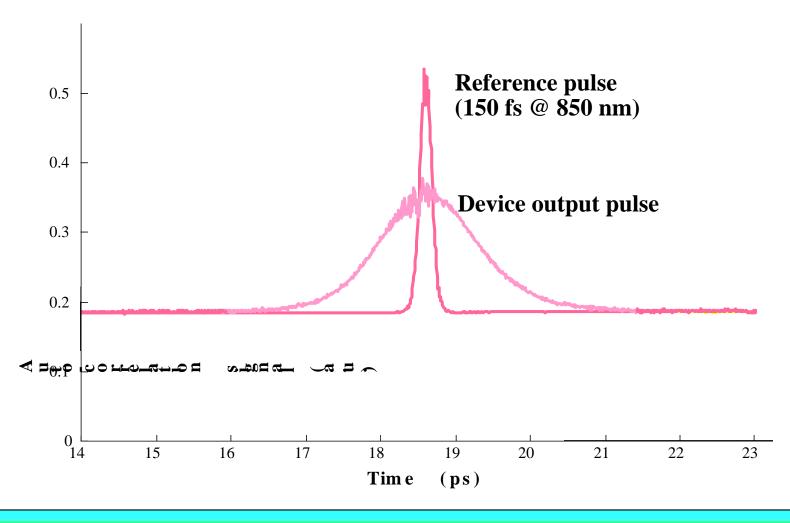


## Bi-directional optical backplane

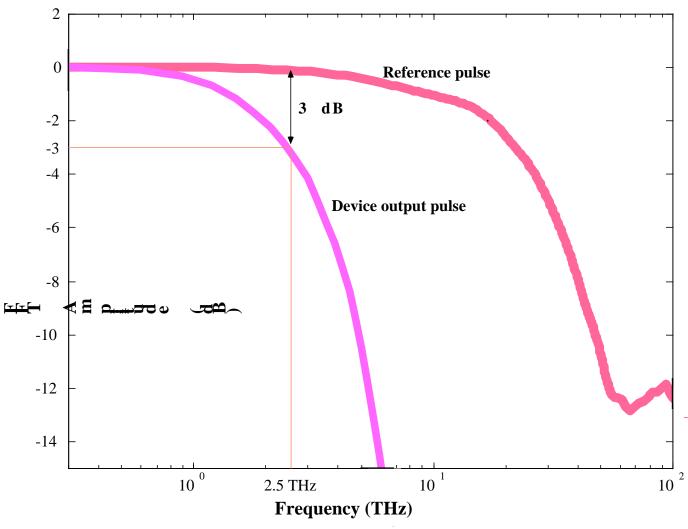
Bandwidth measurement setup



# Pulse broadening by the optical backplane

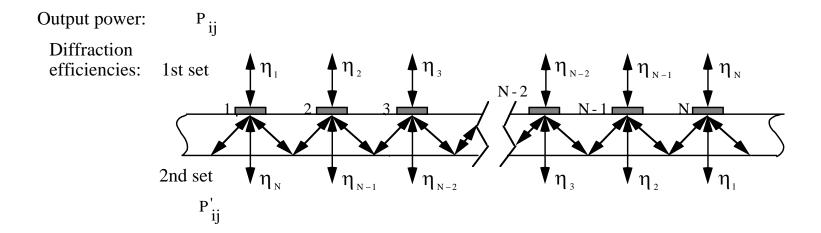






# Fan-out intensity optimization of the optical backplane

Goal: to minimize output intensity fluctuation



## Fan-out intensity optimization

### **Assumptions:**

- (1) Neglect reflections and absorptions
- (2) To prevent power leakage,  $\eta_1 = 1$  and  $\eta_N = 0$

#### **Transmission function**:

energy of substrate guided beam transmitted from one output channel to the next

# Fan-out intensity optimization process

- (1) Express fan-out intensities as functions of diffraction efficiencies  $\eta_i$  (i = 1, ..., N 1) of multiplexed holograms
- (2) Establish an objective function

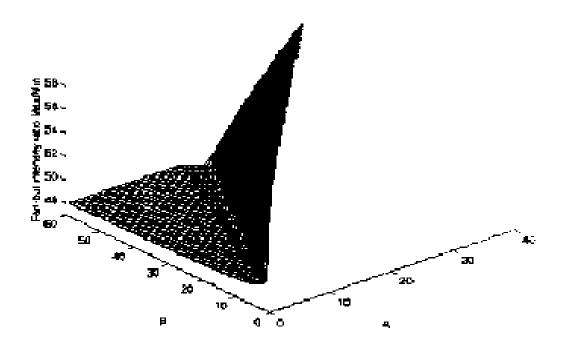
$$\begin{split} E &= E_1 + E_2 \\ E_1 &= \sum_{i=1}^{M} \left[ \sum_{\substack{j=1 \\ j \neq i}}^{N} W_{1\,ij} \left( \frac{P_{ij}}{\overline{P}} - 1 \right)^2 + \sum_{j=2}^{N-1} W_{1ij}^{'} \left( \frac{P_{ij}^{'}}{\overline{P}} - 1 \right)^2 \right] & \text{for } P_{ij} \text{ and } P_{ij}^{'} \geq \overline{P}, \\ E_2 &= \sum_{i=1}^{M} \left[ \sum_{\substack{j=1 \\ j \neq i}}^{N} W_{2\,ij} \left( \frac{\overline{P}}{P_{ij}} - 1 \right)^2 + \sum_{j=2}^{N-1} W_{2\,ij}^{'} \left( \frac{\overline{P}}{P_{ij}^{'}} - 1 \right)^2 \right] & \text{for } P_{ij} \text{ and } P_{ij}^{'} < \overline{P}, \\ \text{where } W_{1\,ij}^{(')} \text{ and } W_{2\,ij}^{(')} & \text{are weight factors} \end{split}$$

(3) Optimize the objective function through solving

$$\frac{\partial \mathbf{E}}{\partial \eta} = 0$$
,  $i = 2, ..., N$ 

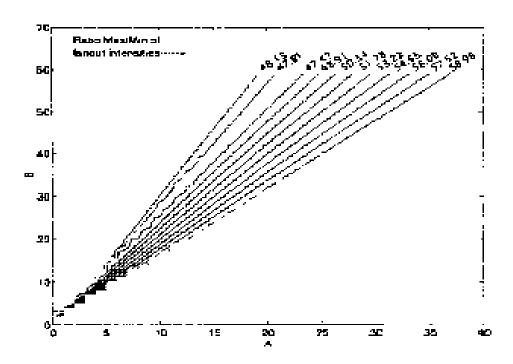
$$W_{_{1\,ij}}^{\,(')} = exp \Bigg[ A \Bigg( \frac{P_{_{ij}}}{\overline{P}} - 1 \Bigg) \Bigg] \qquad \text{for } P_{_{ij}}^{\,(')} \geq \overline{P},$$

$$W_{1ij}^{(')} = exp\left[A\left(\frac{P_{ij}}{\overline{P}} - 1\right)\right] \quad \text{for } P_{ij}^{(')} \geq \overline{P}, \qquad W_{2ij}^{(')} = exp\left[B\left(\frac{\overline{P}}{P_{ii}} - 1\right)\right] \quad \text{for } P_{ij}^{(')} < \overline{P},$$

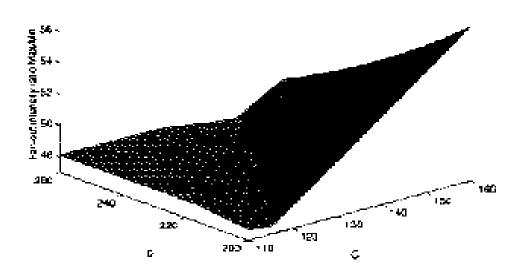


$$W_{1ij}^{(\prime)} = exp \left[ A \left( \frac{P_{ij}}{\overline{P}} - 1 \right) \right] \quad \text{for } P_{ij}^{(\prime)} \ge \overline{P},$$

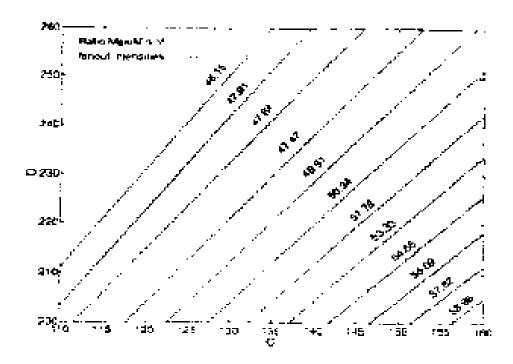
$$W_{1ij}^{(')} = exp \left[ A \left( \frac{P_{ij}}{\overline{P}} - 1 \right) \right] \quad \text{for } P_{ij}^{(')} \ge \overline{P}, \qquad W_{2ij}^{(')} = exp \left[ B \left( \frac{\overline{P}}{P_{ij}} - 1 \right) \right] \quad \text{for } P_{ij}^{(')} < \overline{P},$$



Different weight factors: 
$$W_{1ij}^{(')} = \left(\frac{P_{ij}}{\overline{P}} - 1\right)^{C} \quad \text{for } P_{ij}^{(')} \ge \overline{P} \quad W_{2ij}^{(')} = \left(\frac{\overline{P}}{P_{ij}} - 1\right)^{D} \quad \text{for } P_{ij}^{(')} < \overline{P}$$



Different weight factors: 
$$W_{1ij}^{(')} = \left(\frac{P_{ij}}{\overline{P}} - 1\right)^{C} \quad \text{for } P_{ij}^{(')} \ge \overline{P} \quad W_{2ij}^{(')} = \left(\frac{\overline{P}}{P_{ij}} - 1\right)^{D} \quad \text{for } P_{ij}^{(')} < \overline{P}$$



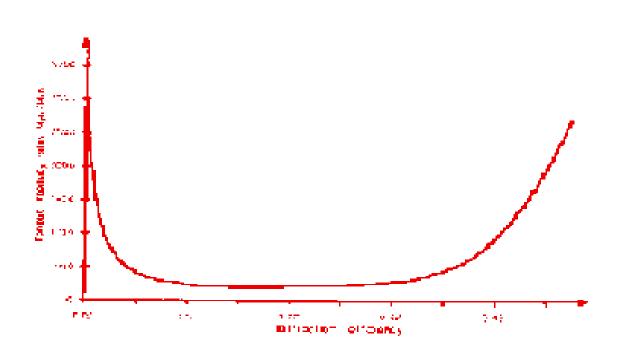
## Optimized fan-out distribution

Optimized diffraction effiency distribution:

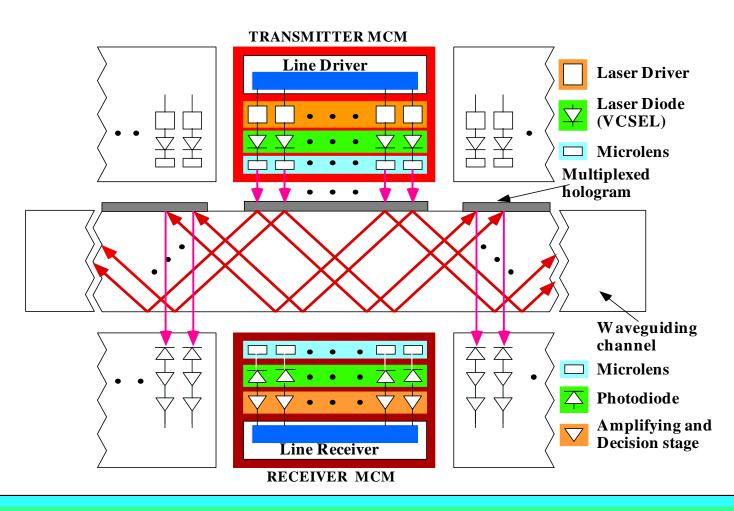
$$(\eta_1, \ \eta_2, ..., \eta_9) = (1.0, 0.3341, 0.2005, 0.1435, 0.1548, 0.1665, 0.2492, 0.4984, 0.0)$$

' 9'									
Fanout	1	2	3	4	5	6	7	8	9
P <sub>1 j</sub>	0	0.27791	0.05833	0.02493	0.01860	0.01852	0.01698	0.01587	0.02131
P <sub>1 j</sub>	0	0.16213	0.05758	0.02972	0.01653	0.01587	0.01587	0.01586	0
P <sub>2j</sub>	0.44513	0	0.05853	0.02502	0.01867	0.01859	0.01703	0.01591	0.02138
P' <sub>2 j</sub>	0	0.17921	0.05777	0.02982	0.01659	0.01591	0.01591	0.01590	0
P 3j	0.07579	0.04219	0	0.02490	0.01858	0.01850	0.01696	0.01569	0.02129
P 3j	0	0.04218	0.56723	0.02968	0.01651	0.01586	0.01586	0.01569	0
P 4 j	0.02993	0.01666	0.02384	0	0.01858	0.01850	0.01696	0.01569	0.02128
P 4 j	0	0.01666	0.01667	0.70316	0.01651	0.01586	0.01586	0.01569	0
P <sub>5j</sub>	0.02132	0.01587	0.01698	0.01853	0	0.01853	0.01698	0.01587	0.02132
P sj	0	0.01587	0.01588	0.01588	0.74511	0.01588	0.01588	0.01587	0

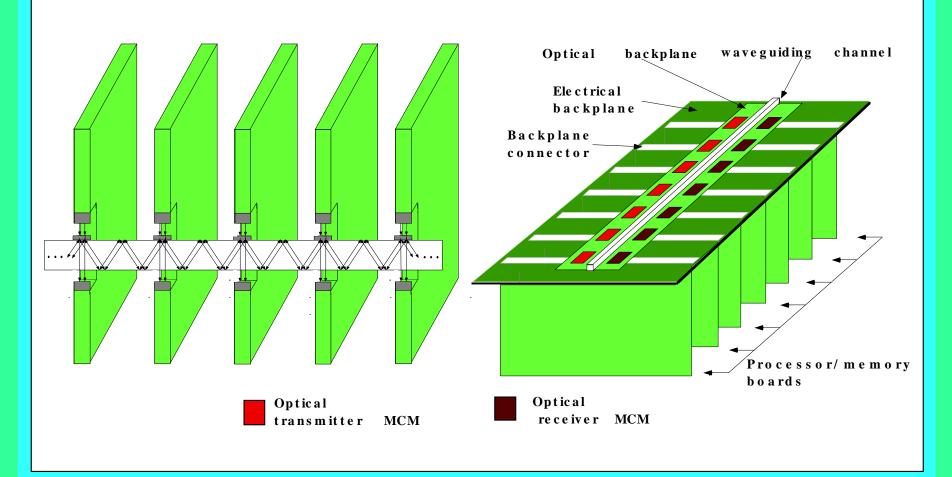
# Fan-out intensity fluctuation of an unoptimized backplane



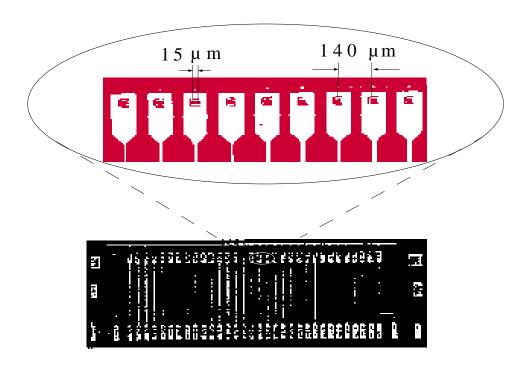
## Bi-directional optical backplane bus with multi-bus lines: channel design



## Bi-directional optical backplane bus with multi-bus lines: configuration



### VCSEL array operating at 850 nm



Very low (1~3 mA or less) threshold current
High direct modulation bandwidth (over 14 GHz)
Moderate optical power (a few mW or more)
Wide operating temperature range (-55 to +125

## Bi-directional optical backplane bus with multi-bus lines

experiment demonstration



1 st



2nd



 $3 \, \text{rd}$ 



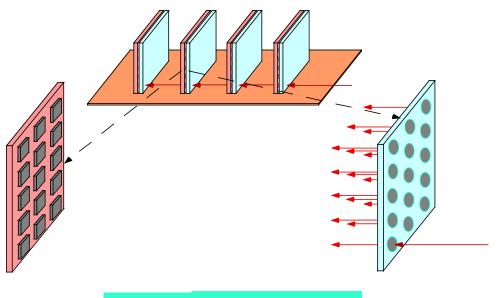
4 t h

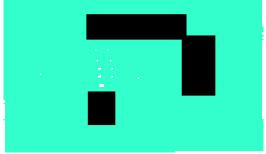


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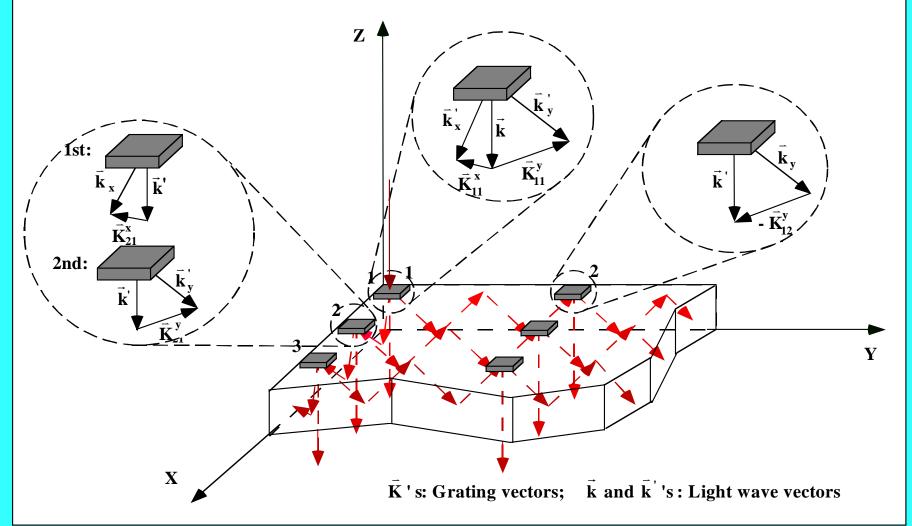


experiment demonstration





**Device Analysis** 



Fan-out intensity optimization (I)

Assume  $M \times N$  fan-outs

**Define:** 

**Diffraction efficiencies:** 

$$\eta_{i}^{x}$$
 (i = 1, ..., M);  $\eta_{ij}^{y}$  (i = 1, ..., M; j = 1,..., N)

**Transmission functions:** 

$$T_{i}^{x}$$
 (i = 2, ..., M);  $T_{ij}^{y}$  (i = 1, ..., M; j = 2, ..., N)

Fan-out intensities:  $P_{ij}$  (i = 1, ..., M; j = 1, ..., N)

To minimize power consumption, we should have

$$\eta_{M}^{x} = 1; \eta_{N}^{y} = 1 (i = 1, ..., M)$$

So the unknown  $\eta$ 's are  $(M-1)+(M\times N-M)=M\times N-1$ 

Fan-out intensity optimization (II)

From Bragg diffraction analysis, we have (assume an input intensity of 1)

$$\begin{cases}
\mathbf{T}_{2}^{x} = \eta_{1}^{x} \\
\mathbf{T}_{i}^{x} = \mathbf{T}_{i-1}^{x} (\mathbf{1} - \eta_{i-1}^{x}), \quad (\mathbf{i} = 3, ..., \mathbf{M})
\end{cases}$$

$$\begin{cases} T_{i2}^{y} = \eta_{11}^{y} \\ T_{i2}^{y} = T_{i}^{x} \eta_{i}^{x} \eta_{i1}^{y}, & (i = 2, ..., M) \\ T_{ij}^{y} = T_{i,j-1}^{y} (1 - \eta_{i,j-1}^{y}), & (i = 1, ..., M; j = 3, ..., N) \end{cases}$$

$$\begin{cases} P_{11} = 1 - \eta_{11}^{x} - \eta_{11}^{y} \\ P_{i1} = T_{i}^{x} \eta_{i}^{x} (1 - \eta_{i1}^{y}), & (i = 2, ..., M) \\ P_{ij} = T_{ij}^{y} \eta_{ij}^{y}, & (i = 1, ..., M; j = 2, ..., N) \end{cases}$$

Fan-out intensity optimization (III)

#### **Define objective function:**

$$\mathbf{E} = \mathbf{E}_{1} + \mathbf{E}_{2}$$

$$\begin{cases} E_{1} = \sum_{i=1}^{M} \sum_{j=1}^{N} \left( \frac{P_{ij}}{\overline{P}} - 1 \right)^{2} & \text{for } P_{ij} \geq \overline{P}, \ (i = 1, ..., M; j = 1, ..., N), \\ E_{2} = \sum_{i=1}^{M} \sum_{j=1}^{N} \left( \frac{\overline{P}}{P_{ij}} - 1 \right)^{2} & \text{for } P_{ij} < \overline{P}, \ (i = 1, ..., M; j = 1, ..., N) \end{cases}$$

where  $\overline{P} = \frac{1}{M \times N}$  is the average fan-out intensity

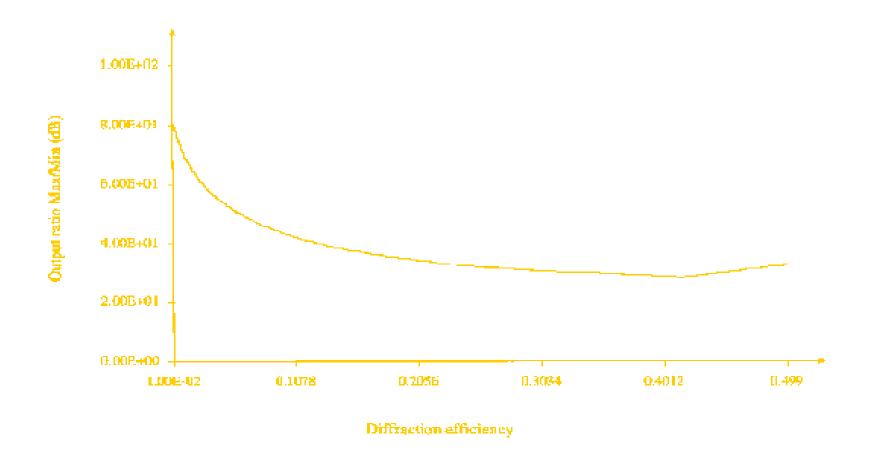
Optimization is carried out by minimizing objective function E

Optimized diffraction efficiency distribution (I)

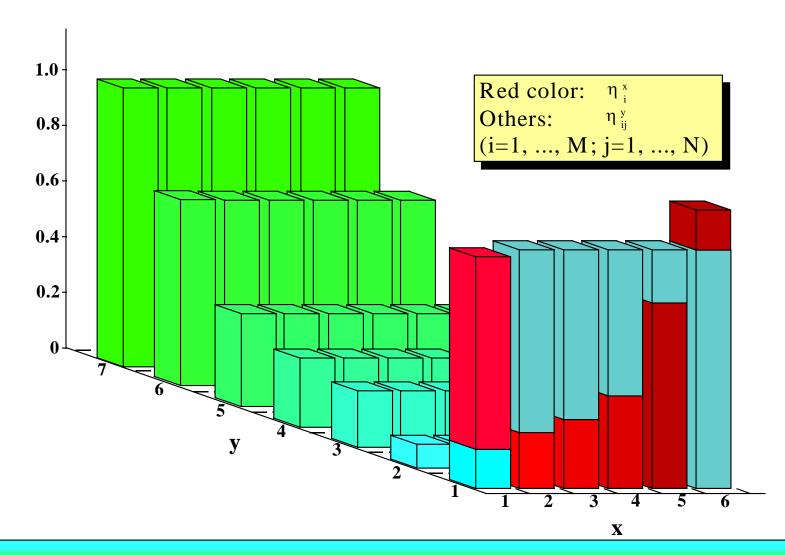
For M = 6 and N = 7,  $\overline{P}$  = 0.0238 , the optimized diffraction efficiency distribution for uniform fan-out intensity distribution is

y x y	$\eta_{i}^{x}$ $\eta_{i1}^{y}$		2	3	4	5	6	7
1	0.833	0.143	0.167	0.200	0.250	0.333	0.500	1.000
2	0.200	0.857	0.167	0.200	0.250	0.333	0.500	1.000
3	0.250	0.857	0.167	0.200	0.250	0.333	0.500	1.000
4	0.333	0.857	0.167	0.200	0.250	0.333	0.500	1.000
5	0.500	0.857	0.167	0.200	0.250	0.333	0.500	1.000
6	1.000	0.857	0.167	0.200	0.250	0.333	0.500	1.000

**Output fluctuation without optimization** 



**Optimized diffraction efficiency distribution (II)** 



**Clock skew and time jittering analyses** 

Time delay: (deterministic) difference in clock paths

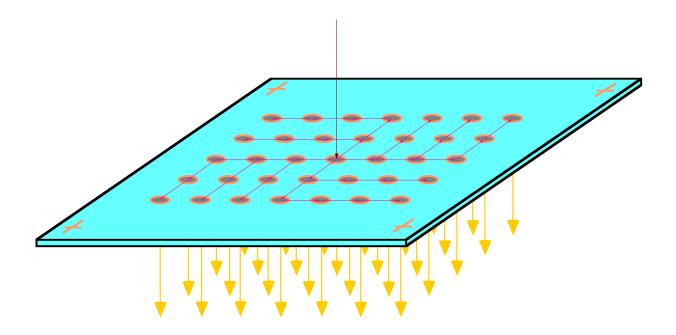
For our device with 6  $\times 7$  fan-outs , waveguide thickness of 1 mm and bouncing angle of 45°

Maximum time delay=150 ps

- Clock skew : (non-deterministic) clock-to-clock variation of clock edges
  - \* spatial skew: variation in fabrication process
  - \* temporal skew:

noise from clock laser, clock device, receiver, etc

Reduction of time delay



#### **Power budget considerations**

APD: At 850 nm, 500 Mbit/s, BER=10 -9 dynamic range 30 dB, sensitivity = -45 dBm

#### Optical clock signal distribution system:

$$P_{out} = \frac{(1 - R)P_{in}}{M \times N}$$

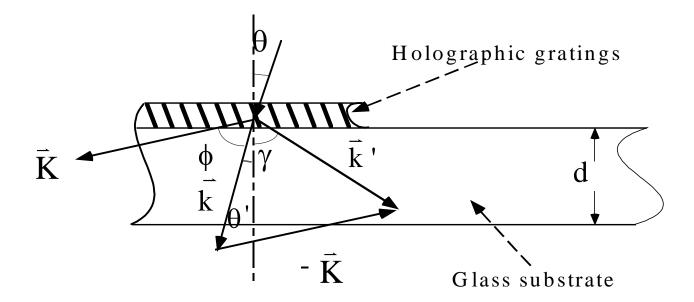
=> required VCSEL power range 1.89 μW-1.89 mW

#### Optical backplane system:

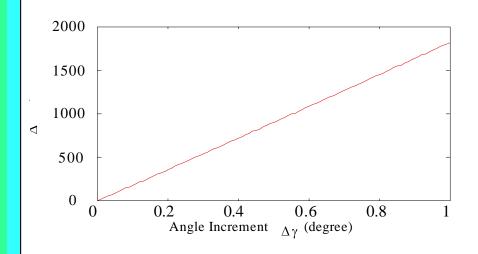
$$P_{out} = \eta(1-R)P_{in}$$

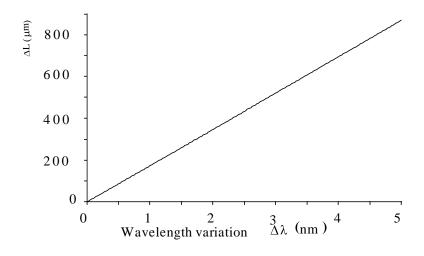
=>required VCSEL power range 3.0 µW-3.0 mW

**Misalignment consideration(I)** 

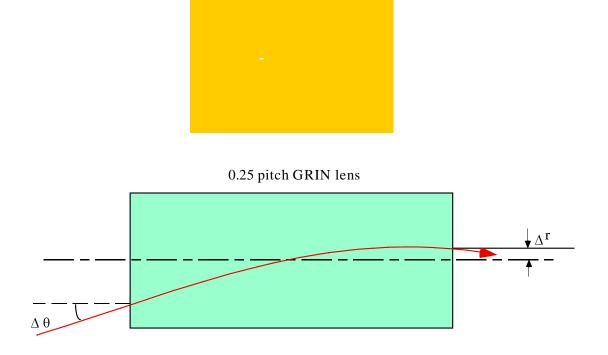


**Misalignment consideration(II)** 



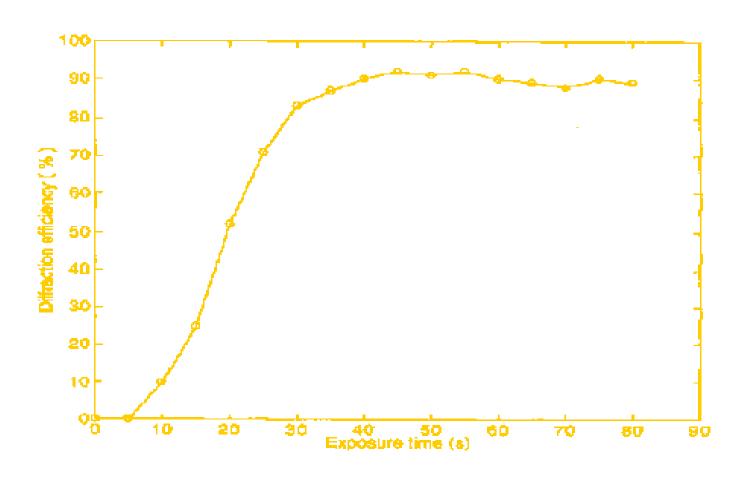


#### **Beam collimation**

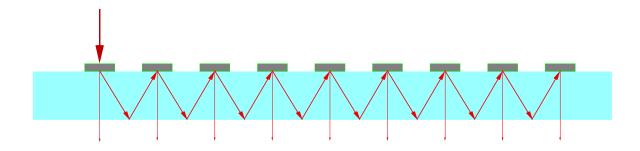


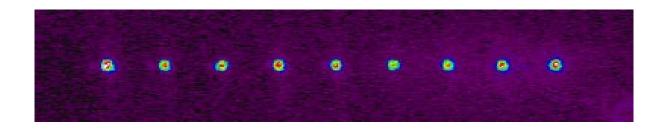
For 2 ° input angle, spatial shift out of GRIN lens 50 µm

**Diffraction efficiency** 

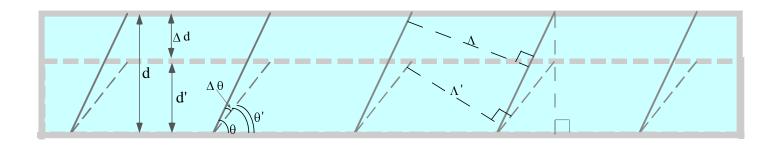


1-to-9 equal fan-out device demonstration



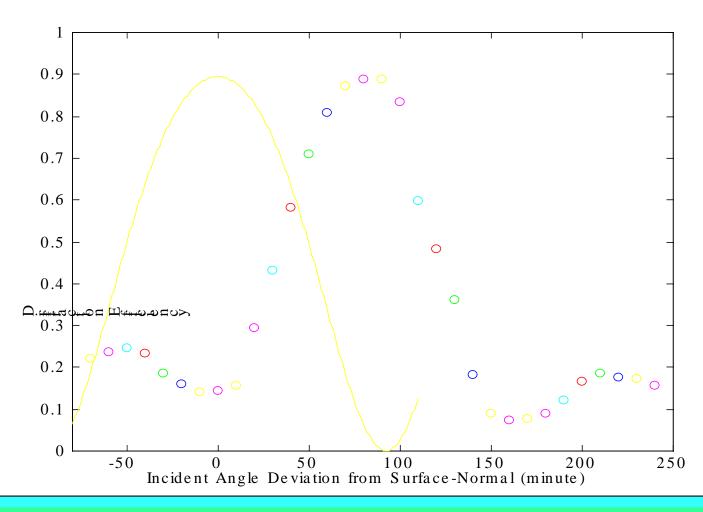


Thickness variation phenomenon

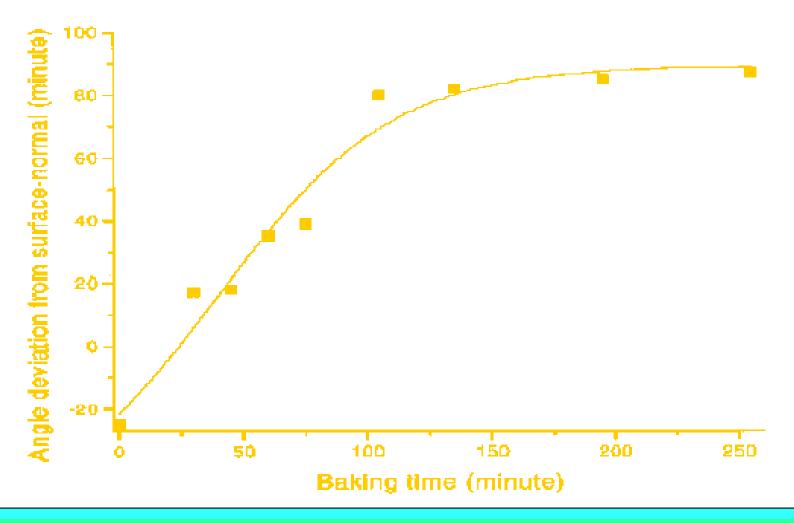


**Refractive index:**  $n(\vec{r}) = n_0 + \Delta n(\vec{r})$ 

Comparison of theoretical and experimental efficiency curves

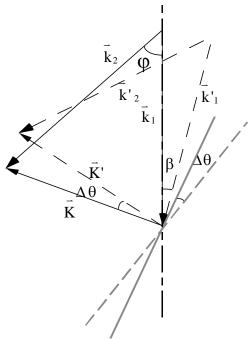


Variation of Bragg angle with baking time



Theoretical study of thickness variation

Surface-normal

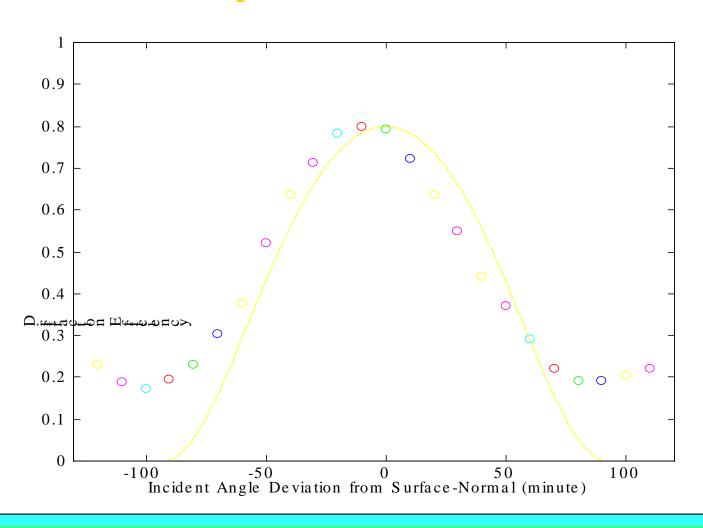


For 20 µm film, deviation angle of 85',

get

 $\Delta d = 1.05 \ \mu m$  Or  $\Delta d \% = 5.25 \%$ 

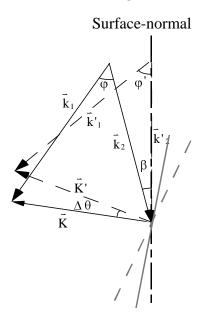
#### **Compensated results**



#### **Compensation for thickness variation**

#### Assumption:

For two holograms fabricated under the same recording beam intensity and recording time, and the same condition for other processes, the resulted relative changes in film thickness wilbe the same



Fabrication of power-budget-optimized devices

(1) Use the results from the experiment of Dupont photopolymer efficiency measurement

Tune the efficiencies of the holographic gratings according to optimization results

(2) Use the compensation method to adjust the Bragg condition to be surface-normal

Time jittering measurement of the clock distribution device

- (1) Directly modulate a VCSEL with a digital signal synthesizer
- (2) Measure the output signals with and without the device
- (3) By comparing the transition times for the signal edges crossing the threshold level, can get the jittering due to the device

Eye diagram measurement of the devices

- (1) Modulate the VCSEL with a randomized bit generator with a periodic (2<sup>31</sup>pse)udorandom bit sequence
- (2) Measure the output signals from the detector with and without the devices
- (3) Compare the eye patterns to check the performance of the devices

Crosstalk measurement of the backplane device

- (1) Couple the output from a VCSEL into the device using lenses with different radius
- (2) Measure the output signal profiles from the device (Central intensity and FWHM)
- (3) Calculate the crosstalks by assuming a Gaussian distribution of the profiles

Finally, integrate the VCSEL arrays and detectors

(arrays, if we can get some)

for system demonstration